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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/665,991	09/19/2003	Henry V. Allen	019963-001200US	5384	
20350	7590 06/06/2005		EXAM	INER	
TOWNSEND AND TOWNSEND AND CREW, LLP			ELLINGTON, ALANDRA		
TWO EMBAR EIGHTH FLO	RCADERO CENTER OOR		ART UNIT	PAPER NUMBER	
SAN FRANCI	ISCO, CA 94111-3834	2855			
				DATE MAILED: 06/06/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	A	T-A - 1: - 1: - 1: - 1: - 1: - 1: - 1: -				
	Application No.	Applicant(s)				
	10/665,991	ALLEN ET AL.				
Office Action Summary	Examiner	Art Unit				
·	Alandra Ellington	2855				
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with the o	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above, the maximum statutory perions of the period for reply is specified above, the maximum statutory perions are period for reply within the set or extended period for reply will, by stated any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply be tireply within the statutory minimum of thirty (30) day od will apply and will expire SIX (6) MONTHS from tute, cause the application to become ABANDONE	nely filed rs will be considered timely. the mailing date of this communication. CD (35 U.S.C. § 133).				
Status ·						
1) Responsive to communication(s) filed on 15	March 2005.					
	<u>_</u>					
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4)	rawn from consideration. d.					
Application Papers						
9) ☐ The specification is objected to by the Exami 10) ☑ The drawing(s) filed on 19 September 2003 Applicant may not request that any objection to the Replacement drawing sheet(s) including the corrupt The oath or declaration is objected to by the	is/are: a)⊠ accepted or b)⊡ object he drawing(s) be held in abeyance. Se ection is required if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for forei a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a li	ents have been received. ents have been received in Applicat riority documents have been receiv eau (PCT Rule 17.2(a)).	ion No ed in this National Stage				
Attachment(s)						
1) Motice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail D	ate				
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/N Paper No(s)/Mail Date	5) Notice of Informal F 6) Other:	Patent Application (PTO-152)				

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Non-Final Rejection

Election/Restrictions

1. Claims 1-3, 6-8, 12-14 and 19 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 3/15/05.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 4 and 5 are rejected under 35 U.S.C. 102(b) as being anticipated by Hoffman et al (6,341,528) (hereinafter Hoffman).
 - a. With respect to Claim 4, Hoffman discloses a pressure sensor comprising a horizontal diaphragm 4 having a top and a bottom; a silicon sidewall 1 formed using MEMS micro-machining and extending from the bottom of the diaphragm 4, the sidewall 1 having an interior side forming a backside cavity, the backside cavity having a backside opening, the interior side substantially vertical; and a boss 5 attached to the bottom of the diaphragm 4, the boss 5 separate from the sidewall 1 (col. 3 lines 12-42 {Figs. 1, 2}).

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b. With respect to Claim 5, Hoffman discloses the pressure sensor of claim 4, wherein the silicon sidewall 1 is formed using deep reactive ion etch (col. 3 lines 23-35,63-67, col. 4 lines 14-17,40-42).

Allowable Subject Matter

- 4. Claims 9-11, 15-18 and 20-24 are allowed.
- 5. The following is an examiner's statement of reasons for allowance: The reasons for allowance are based on the inclusion of:
 - a. In Claim 9, the interior side of the sidewall is formed using a deep reactive ion etch and is substantially orthogonal to the diaphragm, and wherein the backside opening is non-rectangular.
 - b. In Claim 15, the interior side substantially orthogonal to the diaphragm; and a block covering the backside opening such that a hermetic seal is formed.
 - c. In Claim 20, the plurality of pressure sensor includes approximately at least twenty-thousand pressure sensors, and wherein the silicon wafer is a 150mm (6 inch) wafer.
 - d. In Claim 21, wherein the diaphragm is less than 350 microns in length, and the diaphragm accounts for more than 10 percent of an area of the exactly one pressure sensor.
 - e. In Claim 22, the interior side substantially orthogonal to the diaphragm; a cap attached to the top of the diaphragm, wherein the cap and diaphragm form a reference cavity.

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Conclusion

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

(6,651,506) (6,874,367)

- 7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alandra Ellington whose telephone number is (571) 272-2178. The examiner can normally be reached on Monday Friday, 7:30am 4:00pm.
- 8. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Edward Lefkowitz can be reached on (571) 272-2180. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.
- 9. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Alandra Ellington Art Unit 2855

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William Oen Primary Examiner